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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE  
(207.005-US)

Application of: **Partridge et al.**

Serial No: **10/713,172**

Filed: **November 14, 2003**

Title: **Crack and Residue Free Conformal Deposited  
Silicon Oxide with Predictable and Uniform  
Etching Characteristics**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

) Group Art Unit: **1762**

) Examiner:

I hereby certify that this  
correspondence is being deposited  
with the United States Postal Service  
as first class mail with sufficient  
postage in an envelope addressed to  
the Commissioner for Patents, P.O.  
Box 1450, Alexandria, VA 22313-1450  
on May 12, 2004

Michiko Siter Date  
(person signing this certificate)

Michiko Siter  
Signature

**FIRST INFORMATION DISCLOSURE STATEMENT**

Dear Sir:

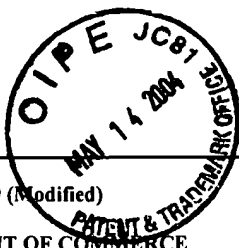
Submitted herewith is one (1) sheet of a modified Form PTO-1449. A copy of each  
document cited on the attached Form PTO-1449 is also submitted.

It is respectfully requested that the Examiner make his/her consideration of these  
documents formally of record with the initial Office Action.

Respectfully submitted,

Date: May 12, 2004

Neil A. Steinberg  
Reg. No. 34,735  
650-968-8079



PTO-1449 (Modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE  INFORMATION DISCLOSURE STATEMENT BY APPLICANT	ATTY. DOCKET NO. <b>207.005-US</b>	SERIAL NUMBER <b>10/713,172</b>
	APPLICANT(S) <b>Partridge et al.</b>	
	FILING DATE <b>November 14, 2003</b>	GROUP ART UNIT <b>1762</b>

## U.S. PATENT DOCUMENTS

EXAMINER INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE
	6,318,175	11/2001	Muchow et al.			
	5,922,212	7/1999	Kano et al.			
	5,683,591	11/1997	Offenberg			
	5,804,083	9/1998	Ishii et al.			
	2003/0073293	4/2003	Ferro et al.			

## FOREIGN PATENT DOCUMENTS

EXAMINER INITIALS	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES/NO	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER	DATE CONSIDERED
EXAMINER: Initial citation if reference was considered. Draw line through citation if not in conformance to MPEP 609 and not considered. Include copy of this form with next communication to applicant.	